

The 3rd time prize "Technology & Development Award" of Toyota Motor Corporation.

— Development of Flux Application by Dot method —

Toyota Motor Corporation (hereafter TMC) had " 2013 Toyota global supplier general meeting " in Nagoya Congress Center on 21st Feb. 2013.

Chairman Mr. Zhang, President Mr.Toyoda, and Approx.100 executives and employees of TMC attended This meeting and there were Approx. 770 participants from 460 Global Suppliers including SHINWA.

In this meeting, TMC explained 2013 procurement policy and gave 2012 awards for Suppliers. SHINWA is given "Technical Development Award" for Flux Application by Dot method and received a letter of appreciation and memorial plaque from President Mr.Toyoda.

This award is given to the supplier who had great achievements for product improvement of vehicle by the development of new technology and new product on Vehicle Parts and Manufacturing Equipments, SHINWA had been awarded for "Wireless of Robot teach pendant"(2009), and development of "New Tool for Tip Former" (2010). This time award was the 3rd time prize.

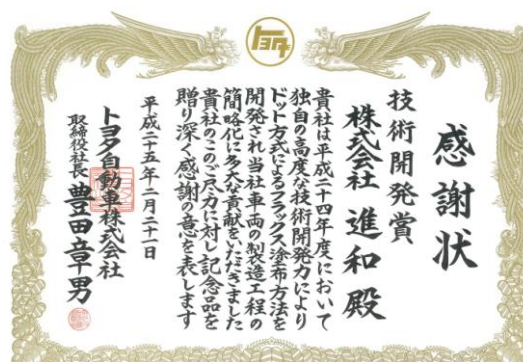
Flux Application by Dot method is the equipment for manufacturing cooling unit for Inverter on Hybrid Vehicle. This equipment dramatically improve application efficiency and saving raw materials to perform application only for the necessary point compared with usual spray method, and evaluated as making sliming and space-saving of the process by reduced washing process of masking to cover unnecessary parts.



< President Mr.Shimokawa received a plaque >



< The supplier who won "Technical Development Award" >



< Letter of application >